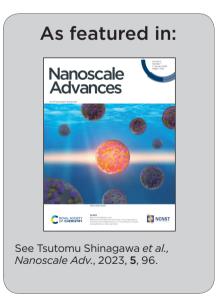


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Oriented growth of stacking  $\alpha$ -cobalt hydroxide salt continuous films and their topotactic-like transformation to oriented mesoporous films of  $\text{Co}_{\alpha}\text{O}_{\alpha}$  and CoO

A unique synthetic route based on "direct oriented growth of layered hydroxide films" and "topotactic-like pseudomorphic transformation" allows the template-free facile formation of oriented mesoporous oxide films. By using this strategy, novel [111]-oriented mesoporous films of  ${\rm Co_3O_4}$  and  ${\rm CoO}$  are successfully obtained from [001]-oriented stacking  $\alpha$ -cobalt hydroxide salt films deposited electrochemically on substrates.





# **Nanoscale Advances**



## PAPER

View Article Online



Cite this: Nanoscale Adv., 2023, 5, 96

# Oriented growth of stacking $\alpha$ -cobalt hydroxide salt continuous films and their topotactic-like transformation to oriented mesoporous films of Co<sub>3</sub>O<sub>4</sub> and CoO†

Tsutomu Shinagawa, • \* Natsuko Kotobuki \* and Atsushi Ohtaka • \*

Mesoporous metal oxide films composed of nanocrystal assemblies with an aligned crystallographic orientation are key nanostructures for efficient interfacial reactions; however, the development of a simple and versatile method for their formation on substrates still constitutes a challenge. Here we report the template-free centimetre-scale formation of novel cobalt oxide films of Co<sub>3</sub>O<sub>4</sub> and CoO with a [111]-oriented mesoporous structure starting from stacking cobalt hydroxide continuous films. The cobalt hydroxide precursor is formed electrochemically on conductive substrates from a Co(NO<sub>3</sub>)<sub>2</sub> aqueous solution at room temperature. A thorough characterization by means of scanning electron microscopy, X-ray diffraction, X-ray photoelectron spectroscopy, UV-vis-NIR spectroscopy, IR spectroscopy and Raman spectroscopy analyses reveals that the precursor film is an α-type layered cobalt hydroxide salt ( $\alpha$ -Co-LHS) containing interlayer nitrate and hydrated water, i.e.,  $\alpha$ - $Co(OH)_x(NO_3)_v \cdot nH_2O_t$ , with a [001]-oriented stacking film structure. Heat treatment of the [001]- $\alpha$ -Co-LHS films using different conditions, i.e., under air at 550 °C or under vacuum at 500 °C, results in the selective formation of Co<sub>3</sub>O<sub>4</sub> or CoO mesoporous films, respectively. A plausible explanation for the observed centimetre-scale topotactic-like transformation from  $\alpha$ -Co-LHS[001] to Co $_7$ O $_4$ [111] or CoO [111] is given according to the atomic framework similarity between the hydroxide precursor and the final oxides

Received 3rd September 2022 Accepted 18th October 2022

DOI: 10.1039/d2na00594h

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#### Introduction

Metal oxide-based mesoporous structures consisting of numerous nanopores have attracted increasing attention for application as (photo)electrocatalysts, chemical sensors and adsorbents because of the synergistic combination of their diverse physical and chemical properties and large surface area easily accessible from the outside. 1-5 Mesoporous oxides are generally synthesized using templates such as surfactants and polymers.<sup>1,6</sup> However, the formation and removal of templates complicates the synthesis process and generates residues. Consequently, the use of layered metal hydroxides (LMHs) as precursors has emerged as an alternative simple and templatefree method for synthesizing mesoporous oxides.7-9

LMHs have a layered structure comprising two-dimensional (2D) edge-shared octahedral hydroxide sheets and can be divided into layered double hydroxides with a composition of  $M_{1-x}^{II}M_{x}^{III}(OH)_{2}(A^{m-})_{x/m}\cdot nH_{2}O$  containing divalent (Mg, Co, Ni, Cu, Zn, etc.) and trivalent (Al, Cr, Co, Fe, In, etc.) cations and layered hydroxide salts (LHSs)  $M^{II}_{x}(OH)_{2x-my}A^{m-}_{y} \cdot nH_{2}O$  consisting of only divalent cations. <sup>10,11</sup> Anions  $(A^{m-})$  such as  $Cl^-$ , NO<sub>3</sub><sup>-</sup>, SO<sub>4</sub><sup>2-</sup> and CO<sub>3</sub><sup>2-</sup> are often incorporated between the hydroxide layers and participate in anion exchange reactions. Moreover, thermal decomposition of LMHs proceeds via anion elimination and dehydration reactions, usually without an external oxygen source, to form the corresponding metal oxides consisting of numerous oxide nanocrystals. Interestingly, some LMHs yield nanoporous oxides during the decomposition process while maintaining their apparent atomic arrangement and original crystal shape, that is, they exhibit topotactic-like pseudomorphic transformation (TPT) property.8,12-14 This TPT feature allows the template-free facile formation of crystallographically oriented nanoporous oxides.

Cobalt oxides (Co<sub>x</sub>O<sub>y</sub>), including cobalt(II, III) oxide (Co<sub>3</sub>O<sub>4</sub>) and cobalt(II) oxide (CoO), are among the most studied oxides prepared from LHS precursors because of their application in anode materials for lithium ion batteries, 15,16 electrochemical

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<sup>†</sup> Electronic supplementary information (ESI) available: FESEM images, XPS spectra, XRD patterns, Raman spectra, ATR-FTIR spectra and photographs of the obtained samples. See DOI: https://doi.org/10.1039/d2na00594h

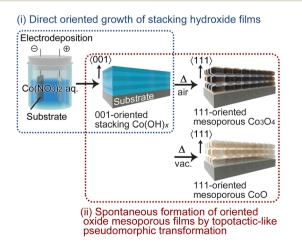
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capacitors 17,18 and (photo)electrocatalysts for water splitting reactions (both hydrogen and oxygen evolution reactions)19-22 and for CO2 reduction.23,24 Several types of cobalt-based LHSs (Co-LHSs), e.g.,  $Co(OH)_2$ ,  $Co_2(NO_3)(OH)_3$  and  $Co_7(NO_3)_2(OH)_{12}$ , have been synthesized by means of alkaline precipitation and hydrothermal methods.<sup>25-30</sup> Furthermore, thermal decomposition of Co-LHSs to Co<sub>x</sub>O<sub>y</sub> has been reported to proceed via TPT with a crystallographic orientation relationship of Co-LHS [001]//Co<sub>3</sub>O<sub>4</sub>[111] and Co-LHS[001]//CoO[111]. 14,29,31,32

By taking advantage of this TPT property, mesoporous Co<sub>r</sub>O<sub>v</sub> films with a preferred growth orientation can be formed on substrates without using templates. In fact, Ma et al. reported the formation of [111]-oriented Co<sub>3</sub>O<sub>4</sub> and CoO thin films on substrates via Langmuir-Blodgett coating of separately synthesized Co-LHS platelets to ensure a [001] orientation, followed by heat treatment.<sup>32</sup> As an alternative to this stepwise procedure, the direct formation of oriented Co-LHS films on a substrate could dramatically simplify the formation process of oriented mesoporous  $Co_xO_y$  films.

In addition to the large surface area, oriented mesoporous  $Co_xO_y$  films are expected to (i) enhance catalytic activity due to the exposure of specific crystalline planes and (ii) improve charge transport efficiency due to lattice matching between  $Co_xO_y$  nanocrystals.<sup>33-36</sup> In particular, the (111) plane has been reported to be more catalytically active for water splitting and CO oxidation than the (110) and (100) planes. <sup>37–39</sup> Therefore, due to the topotactic relationship of Co-LHS[001]//Co<sub>x</sub>O<sub>y</sub>[111], [001]oriented Co-LHS films are an attractive candidate to spontaneously provide a myriad of oriented  $Co_xO_y$  nanocrystals with the (111) exposed plane. Co-LHSs can be grown directly on substrates via electrochemical deposition in aqueous solution.40-44 However, unoriented Co-LHSs with a flake-like morphology are usually obtained, and epitaxial techniques using single-crystal substrates have to be adopted for their orientation.45 Thus, growing oriented films of Co-LHSs readily without using templates or epitaxial techniques is still a challenge.

Recently, we demonstrated the potential of electrochemical deposition for the growth of oriented LHS films. Specifically,



Scheme 1 Schematic illustration of the template-free synthesis of oriented cobalt oxide mesoporous films.

under the appropriate conditions, even simple electrodeposition in aqueous solution was shown to produce directly [001]oriented continuous Mg- and Ni-LHS films, which then undergo a TPT process to yield [111]-oriented nanoporous MgO and NiO films.46,47 Herein, we report the first successful formation of [001]-oriented Co-LHS continuous films via direct electrodeposition on glass substrates coated with F-doped SnO<sub>2</sub> (FTO) and their heat treatment under different conditions to selectively yield mesoporous Co<sub>3</sub>O<sub>4</sub> or CoO films with a [111] crystal orientation (Scheme 1). In addition, we discuss the observed centimetre-scale topotactic-like transformation on the basis of the similarity of the atomic frameworks between the hydroxide precursor and the final oxides.

## Results and discussion

#### Electrodeposition and characterization of Co-LHS films

Co-LHS was electrochemically deposited on an FTO substrate from a simple aqueous solution containing 10 mM Co(NO<sub>3</sub>)<sub>2</sub> without pH adjustment (pH  $\sim$  5.9). A constant cathodic current of -1.0 mA cm $^{-2}$  was applied on the FTO substrate using a platinum plate counter electrode at room temperature. The deposition process can be described by the following reactions:48

$$NO_3^- + H_2O + 2e^- \rightarrow NO_2^- + 2OH^-$$
 (1a)

$$2H_2O + 2e^- \rightarrow H_2 + 2OH^-$$
 (1b)

$$Co^{2+} + 2OH^{-} \rightarrow Co(OH)_{2}$$
 (2a)

$$\text{Co}^{2+} + x\text{OH}^- + y\text{NO}_3^- + n\text{H}_2\text{O} \rightarrow \text{Co}(\text{OH})_x(\text{NO}_3)_y \cdot n\text{H}_2\text{O}(2\text{b})$$

The cathodic reactions of NO<sub>3</sub><sup>-</sup> and H<sub>2</sub>O occurs on the electrolyte/FTO interface to give OH ions (eqn 1a and 1b), causing an increase in local pH near the FTO surface that induces the precipitation of cobalt hydroxides (eqn 2a and 2b). The pH at which precipitation occurs can be estimated to be above 7.3 using a thermodynamic Pourbaix diagram, according to which further dehydration of hydroxides to form CoO  $(Co(OH)_2 \rightarrow CoO + H_2O)$  is thermodynamically unfavorable at room temperature.49

Electrodeposition by passing a total electricity of -0.2 C  $cm^{-2}$  (deposition time = 3.3 min) resulted in pale light blue deposits on the substrate, which was rinsed with deionized water and then vacuum dried. Fig. 1a shows field-emission scanning electron microscopy (FESEM) images of the deposits, in which a lamellar continuous film structure with a thickness of  $\sim$ 400 nm can be observed. In the 1.5 cm  $\times$  2.5 cm deposition area, the film thickness distribution within the central 1.0 cm  $\times$  1.5 cm area was evaluated to be approximately  $\pm 6.5\%$  based on FESEM observation. The cross-sectional image shows approximately 10 layers with a thickness of 30-40 nm stacked parallel to the substrate, and the plan-view image displays continuous film with no distinct grain boundaries and a slightly wavy surface (FESEM images taken at low magnification are shown in Fig. S1 in the ESI†). This film structure is

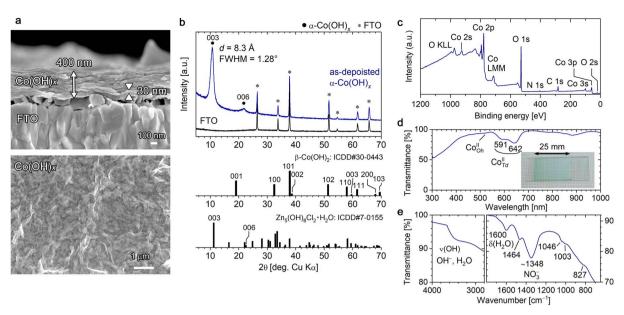


Fig. 1 Characterization of [001]-oriented cobalt hydroxide films electrodeposited on F-doped SnO<sub>2</sub> (FTO) substrates in Co(NO<sub>3</sub>)<sub>2</sub> aqueous solution: (a) cross-sectional (top) and plan-view (bottom) FESEM images, (b) out-of-plane XRD patterns, (c) XPS wide spectra, (d) UV-vis-NIR transmittance spectrum and (e) ATR-FTIR spectrum. ICDD data for β-Co(OH)<sub>2</sub> (no. 30-0443) and simonkolleite (no. 7-0155) and a photograph of the sample are presented in (b) and (d), respectively.

similar to that of the [001]-oriented Mg-LHS films reported in our previous work.46

Fig. 1b shows the  $\theta$ –2 $\theta$  X-ray diffraction (XRD) pattern of the as-deposited film. A distinct broad peak with a full width at half maximum (FWHM) of 1.28° was observed at  $2\theta = 10.71$ ° with a lattice plane distance of 8.3 Å, and no other peaks were detected except for a secondary diffraction at  $2\theta = 21.9^{\circ}$  and diffractions from the FTO substrate. This suggests that the obtained films consist of [001]-oriented Co-LHS with an interlayer distance  $(d_i)$  of 8.3 Å stacked parallel to the substrate surface. In addition, a similar distinct broad peak at  $2\theta = 9.9^{\circ}$  ( $d_i = 8.9 \text{ Å}$ ) appeared in a film that was dried naturally instead of vacuum dried after electrodeposition, confirming that the interlayer distance became slightly larger (the XRD pattern of the naturally dried film is shown in Fig. S2†). These interlayer distances are nearly twice than that of  $\beta$ -Co(OH)<sub>2</sub> ( $d_i = 4.6 \text{ Å}$ , ICDD no. 30-0443) and close to that of  $Zn_5(OH)_8Cl_2 \cdot H_2O$  ( $d_i = 7.9 \text{ Å}$ , simonkolleite, ICDD no. 7-0155) and  $Zn_5(OH)_8(NO_3)_2 \cdot 2H_2O$  ( $d_1$ = 9.7 Å, ICDD no. 72-0627). The large FWHM  $(1.28^{\circ})$  suggests that a crystallite smaller than 10 nm with low crystallinity was obtained.

Wide-scan X-ray photoelectron spectroscopy (XPS) confirmed that the resulting Co-LHS films contained nitrogen as well as cobalt and oxygen atoms, and no impurities other than adventitious carbon were detected (Fig. 1c). Fine XPS measurements in the N 1s region showed a peak at 406.5 eV that can be attributed to NO<sub>3</sub> ions, 50 suggesting the presence of NO<sub>3</sub><sup>-</sup> ions in the interlayer of the obtained Co-LHS (Fig. S3a†). In the O 1s and Co 2p regions, typical peaks for metal hydroxides and Co(II) were observed at 531.2 and 780.5 eV, respectively,<sup>51</sup> and no peaks originating from oxides, Co(0), or Co(III) species were detected (Fig. S3a†). On the basis of the XPS peak areas, the atomic ratio was estimated to be Co: O: N = 32.8: 65.1:2.1.

The interlayer distance of LHSs generally depends on interlayer substances as well as the structure of the 2D M(OH)<sub>x</sub> sheets. Fig. 2 shows the structure model of five representative types of LHSs, namely, a β-type (Fig. 2a), two hydroxy double salts (Fig. 2b and c) and two α-type LHSs (Fig. 2d and e); these models were drawn using the VESTA software.52 Furthermore, the structure and composition of typical LHSs of each type, their interlayer distance, and characteristic IR bands (lattice OHand interlayer NO<sub>3</sub><sup>-</sup>) are summarized in Table 1. β-Type and hydroxy double salt LHSs can be categorized as ordered layered hydroxides because they often show well-faceted single-crystal grains, and α-type LHSs can be assigned as disordered layered hydroxides due to their low crystallinity and turbostratic stacking. The β-type brucite structure shown in Fig. 2a has 2D M(OH)<sub>r</sub> sheets consisting of edge-sharing octahedrally coordinated (O<sub>b</sub>) metal hydroxides and the smallest interlayer distance of  $\sim$ 4.6 Å due to no interlayer substances. In the hydroxy double salt shown in Fig. 2b, anions are coordinated to the Oh hydroxide sheets and the interlayer distance is typically  $\sim$ 6.9 Å. The hydroxy double salt depicted in Fig. 2c comprises 2D  $M(OH)_x$  sheets consisting of  $O_h$  hydroxide sheets partially sandwiched with tetrahedrally coordinated (T<sub>d</sub>) hydroxides, anions coordinated to or intercalated between the Oh-Td hydroxide sheets and a relatively large interlayer distance of 7-15 Å that varies depending on the anion species. The structure shown in Fig. 2d is typical of α-nickel hydroxides, which are composed of O<sub>h</sub> hydroxide sheets similar to those of β-Ni(OH)<sub>2</sub> but with a wider interlayer distance of ~8 Å due to their turbostratic structure with unsettled interlayer H<sub>2</sub>O. This type of LHS often contains interlayer anions.<sup>53</sup> Finally, in the α-type

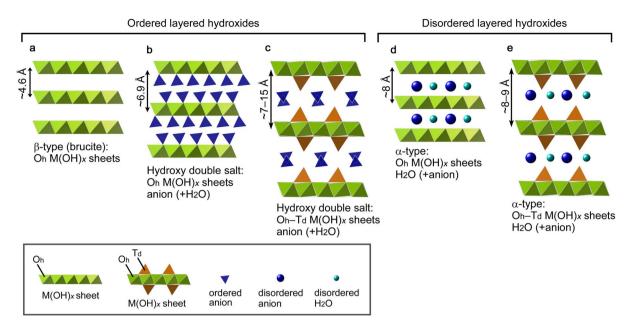


Fig. 2 Structure models of five representative types of layered hydroxide salts: (a) β type, (b and c) hydroxy double salts with (b) octahedrally coordinated  $(O_h)$  and (c)  $O_h$ -tetrahedrally coordinated  $(T_d)$   $M(OH)_x$  sheets, and (d) and (d) (d)

structure depicted in Fig. 2e, the Oh hydroxide sheets are replaced by O<sub>h</sub>-T<sub>d</sub> hydroxide sheets, and α-cobalt hydroxide with a typical interlayer distance of 8-9 Å is a known example.54,55

The structural features observed in the XRD and XPS measurements, *i.e.*, low crystallinity, a large interlayer distance of 8.3-8.9 Å, and the presence of NO<sub>3</sub><sup>-</sup> ions, suggest that the resulting [001]-stacking lamellar Co-LHS film is of the  $\alpha$ -type. To confirm this, UV-vis-NIR, attenuated total reflection (ATR)-FTIR and Raman spectroscopy analyses were performed.

As shown in Fig. 1d, the as-deposited Co-LHS film showed visible transparency as high as ~90%. Absorption peaks

Table 1 Structural and compositional characteristics of the five typical LHS structures shown in Fig. 2

Structure type (sheet type)	Cation	Chemical composition	Interlayer [Å]	Characteristic IR band <sup>a</sup> [cm <sup>-1</sup> ]		
				Lattice OH <sup>-</sup>	NO <sub>3</sub> <sup>-</sup> region	Ref.
$\beta$ (O <sub>h</sub> sheet)	$\mathrm{Co}^{2^+}$	Co(OH) <sub>2</sub>	4.7	3632 (s, sh)	_	27
	$Ni^{2+}$	$Ni(OH)_2$	4.6	3650 (s, sh)	_	56
Double salt ( $O_h$ sheet)	Co <sup>2+</sup>	$Co_2(NO_3)(OH)_3$	6.9	3611 (m, sh) 3527 (m, br)	1491 (s) 1275 (s) 986 (s)	57
	Ni <sup>2+</sup>	$Ni_2(NO_3)(OH)_3$	6.9	~3600 (m, sh) ~3400 (m, br)	1503 (s) 1316 (s) 997 (m)	58
	Cu <sup>2+</sup>	Cu <sub>2</sub> (NO <sub>3</sub> )(OH) <sub>3</sub>	6.9	~3560 (m, sh) ~3450 (m, br)	1428 (s) 1341 (s) 1047 (m, sh)	58
Double salt $(O_h-T_d \text{ sheet})$	$Zn^{2+}$	$Zn_5(NO_3)_2(OH)_8 \cdot 2H_2O$	9.8	3569 (w, sh) 3465 (m, br)	1370 (s)	59
$\alpha$ (O <sub>h</sub> sheet)	Ni <sup>2+</sup>	$Ni(NO_3)_x(OH)_{2-x} \cdot nH_2O$	~8	~3630 (s, br)	~1340 (s) 1310 (s) 1280 (s) 1042 (m) 992 (m)	60
$\alpha$ (O <sub>h</sub> -T <sub>d</sub> sheet)	Co <sup>2+</sup>	$Co(NO_3)_{0.2}(OH)_{1.8} \cdot 0.67H_2O$	8.9	~3450 (m, br)	1491 (m) 1393 (s, sh) 1357 (m)	54
	Co <sup>2+</sup>	$Co(NO_3)_x(OH)_y \cdot nH_2O$	8.7-8.9	~3500 (m, br)	1464 (m) ~1348 (s, br) 1046 (w)	This work

<sup>&</sup>lt;sup>a</sup> Notation: s, strong; m, medium; w, weak; sh, sharp; br, broad.

characteristic of  $T_d$ –Co<sup>2+</sup> were observed at wavelengths of 591 and 642 nm in addition to a less prominent peak at  $\sim$ 520 nm due to  $O_h$ –Co<sup>2+</sup>,<sup>44</sup> indicating that the 2D M(OH)<sub>x</sub> sheet has an  $O_h$ – $T_d$  structure (Fig. 2e). The ATR-FTIR spectrum (Fig. 1e) confirms the absence of a sharp  $\nu$ (OH) band around 3600 cm<sup>-1</sup> that would be attributed to β-type lattice –OH and the presence of  $H_2$ O molecules ( $\delta$ ( $H_2$ O) at 1600 cm<sup>-1</sup>) and  $NO_3$  ions ( $\sim$ 1348 cm<sup>-1</sup>) in the interlayer, which are typical α-type features.

As shown in Table 1, the position and shape of the NO<sub>3</sub><sup>-</sup> IR bands provide information on their state in the interlayer. Monodentate NO<sub>3</sub><sup>-</sup> coordinated to metals (M-O-NO<sub>2</sub>) in regularly stacking 2D M(OH)<sub>x</sub> sheets (Fig. 2b) such as Co<sub>2</sub>(NO<sub>3</sub>)(-OH)<sub>3</sub>, Ni<sub>2</sub>(NO<sub>3</sub>)(OH)<sub>3</sub> and Cu<sub>2</sub>(NO<sub>3</sub>)(OH)<sub>3</sub> usually show sharp doublet peaks at 1428-1503 cm<sup>-1</sup> and 1275-1341 cm<sup>-1</sup>, 57,58 which can be attributed to the asymmetric  $(v_4)$  and symmetric  $(\nu_1)$  NO<sub>2</sub> stretching modes, respectively, with  $C_{2v}$  symmetry. A sharp peak at 986-1047 cm<sup>-1</sup> corresponding to the O-N stretching  $(v_2)$  mode is also characteristic for monodentate NO<sub>3</sub><sup>-</sup>. Meanwhile, nearly free-state NO<sub>3</sub><sup>-</sup> ions regularly packed in the interlayer with hydrogen bonds (Fig. 2c), such as those in Zn<sub>5</sub>(NO<sub>3</sub>)<sub>2</sub>(OH)<sub>8</sub>·2H<sub>2</sub>O, <sup>58,59</sup> show a characteristic intense singlet peak at  $\sim$ 1370 cm<sup>-1</sup> similar to that of solid NaNO<sub>3</sub>, which can be attributed to antisymmetric N-O stretches  $(v_3)$  with  $D_{3h}$ symmetry. In α-type LHSs with interlayer NO<sub>3</sub><sup>-</sup>, due to the low stacking regularity of the 2D M(OH)<sub>x</sub> sheets, the interlayer NO<sub>3</sub> is in an indeterminate state that depends on the synthesis conditions, which may result in a broad peak overlapped with multiple IR bands. Indeed, the FTIR spectra of α-type Ni-LHSs reported by Hall et al.60 suggest the presence of both free and monodentate NO<sub>3</sub><sup>-</sup> in the interlayer.

The  $\alpha$ -Co-LHS obtained in this study (Fig. 2e type) showed a broad strong IR peak at  $\sim \! 1348~cm^{-1}$  accompanied by weak peaks at 1464 and 1046 cm<sup>-1</sup>. The latter two peaks can be

attributed to the  $\nu_4$  and  $\nu_2$  modes characteristic of monodentate NO<sub>3</sub><sup>-</sup>, while the former broad peak is likely a combination of the monodentate  $\nu_1$  mode and the  $\nu_3$  mode of free NO<sub>3</sub><sup>-</sup>, suggesting the presence of both monodentate and free interlayer NO<sub>3</sub><sup>-</sup>.

The Raman spectrum of the obtained  $\alpha$ -Co-LHS films showed two broad peaks at 520 and 458 cm<sup>-1</sup> (Fig. S3b†). According to the literature,  $\beta$ -Co(OH)<sub>2</sub> exhibits several sharp Raman peaks, the most intense at 523 cm<sup>-1</sup> and the second most intense at 457 cm<sup>-1</sup>, which can be attributed to Co-O symmetric stretching mode ( $A_g$ ) and the O-Co-O bending mode, respectively.<sup>51</sup> The Raman peaks observed in the present study exhibited similar positions but were broader, suggesting the low crystallinity of the obtained  $\alpha$ -Co-LHS.

The results shown in Fig. 1 and S3† indicate that the electrodeposited Co-LHS is  $\text{Co(NO}_3)_x(\text{OH)}_y \cdot n\text{H}_2\text{O}$  of an  $\alpha$ -(O<sub>h</sub>-T<sub>d</sub> hydroxide sheet) type with a [001]-oriented continuous film structure. To the best of our knowledge, this is the first example of directly formed oriented continuous films of Co-LHS.

#### Formation of [111]-oriented mesoporous Co<sub>3</sub>O<sub>4</sub> films via TPT

The conversion of the [001]-oriented  $\alpha$ -Co-LHS films to  $\text{Co}_3\text{O}_4$  was conducted by heat treatment at 550 °C for 1 h in air.  $\text{Co}_3\text{O}_4$  is a p-type semiconductor with a cubic spinel structure, where  $\text{Co}^{2^+}$  cations occupy the  $T_d$  sites and  $\text{Co}^{3^+}$  cations occupy the  $O_h$  sites,  $[\text{Co}^{2^+}]_{Td}[2\text{Co}^{3^+}]_{Oh}O_4$ . Upon heating, the colour of the sample changed from pale light blue to dark brown (Fig. S4a†). As shown in Fig. 3a, the continuous lamellar film was converted to a continuous film ( $\sim$ 300 nm in thickness) with a mesoporous structure containing numerous particles with a size of  $\sim$ 70 nm and nanopores having a diameter of  $\sim$ 30 nm.

All diffraction peaks observed in the out-of-plane  $(\theta-2\theta)$  XRD pattern of the mesoporous film (MPF) were ascribable to the

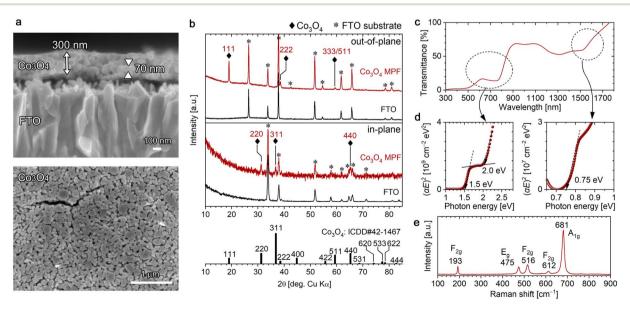


Fig. 3 Characterization of the [111]-oriented  $Co_3O_4$  mesoporous films (MPFs) obtained by heating [001]-oriented Co-LHS at 550 °C for 1 h in air: (a) cross-sectional (top) and plan-view (bottom) FESEM images, (b) out-of-plane (top) and in-plane (bottom) XRD patterns, (c) UV-vis-NIR transmittance spectrum, (d) Tauc plots and (e) Raman spectrum. ICDD data (no. 42-1467) for  $Co_3O_4$  with a cubic spinel structure is presented in (b).

FTO substrate or Co<sub>3</sub>O<sub>4</sub> with a cubic spinel structure (ICDD no. 42-1467); no other phases were detected (Fig. 3b). Peaks attributed to Co<sub>3</sub>O<sub>4</sub> were observed at 18.99°, 38.57° and 59.42° and assigned to 111, 222 and 333/511 diffractions, respectively, indicating that the resulting Co<sub>3</sub>O<sub>4</sub> MPF has a [111] preferred orientation. The crystallite size of the resulting Co<sub>3</sub>O<sub>4</sub> was estimated to be 31 nm using the Scherrer equation. To further confirm the crystal orientation, in-plane XRD measurements were performed to detect crystal planes perpendicular to the substrate surface. In-plane diffraction peaks stemming from Co<sub>3</sub>O<sub>4</sub> were observed at 31.2°, 36.8° and 65.2°, which can be assigned to 220, 311 and 440 diffractions. For the 220 and 440 diffractions, since the angle between the (111) and (1 $\bar{1}0$ ) planes is 90° in the cubic spinel system, the results are consistent with the preferred [111] orientation. For the 311 diffraction, the angle between the (111) and  $(3\bar{1}\bar{1})$  planes is 80°, suggesting the presence of some Co<sub>3</sub>O<sub>4</sub> nanograins with a slightly tilted [111] direction. The fine XPS spectra of the O 1s and Co 2p regions (Fig. S5a†) showed an O 1s peak at 530.0 eV and Co 2p<sub>3/2</sub> peaks at 779.6 and 780.6 eV derived from Co(III) and Co(II), respectively, which are in good agreement with the literature values.51

The UV-vis-NIR transmittance spectrum of the [111]-oriented Co<sub>3</sub>O<sub>4</sub> MPFs (Fig. 3c) showed three absorption edges at wavelengths of  $\sim$ 1600,  $\sim$ 800 and  $\sim$ 600 nm, and the optical bandgaps were estimated to be 0.75, 1.5 and 2.0 eV from the directtransition Tauc plots shown in Fig. 3d. These values are in good agreement with the literature values,61 although the bandgap energy of 0.75 eV in the near-infrared region is not described in some of the reported studies. According to the literature,  $^{61}$  these peaks originate from crystal field  $^{4}A_{2}(F) \rightarrow$ <sup>4</sup>T<sub>1</sub>(F) (0.75 eV) transitions and ligand-metal charge transfer involving  $O^{2-}-Co^{3+}$  (1.5 eV) and  $O^{2-}-Co^{2+}$  (2.0 eV); however, the

electronic structure of spinel Co<sub>3</sub>O<sub>4</sub> is not simple and is still under investigation from both theoretical and experimental aspects.62,63

ATR-FTIR spectrum of the [111]-Co<sub>3</sub>O<sub>4</sub> MPFs confirmed the presence of Co-O vibrations at 678 cm<sup>-1</sup> and the disappearance of NO<sub>3</sub><sup>-</sup> and H<sub>2</sub>O (Fig. S5b†).<sup>64</sup> The formation of Co<sub>3</sub>O<sub>4</sub> with high crystallinity without residues was supported by the corresponding Raman spectra (Fig. 3e), where five sharp Raman bands characteristic of spinel Co<sub>3</sub>O<sub>4</sub> were observed at 193(F<sub>2g</sub>),  $475(E_g)$ ,  $516(F_{2g})$ ,  $612(F_{2g})$  and  $681(A_{1g})$  cm<sup>-1</sup>.65

#### Formation of [111]-oriented mesoporous CoO films via TPT

Interestingly, by subjecting the [001]-oriented  $\alpha$ -Co-LHS films to heat treatment under different conditions from those affording Co<sub>3</sub>O<sub>4</sub>, i.e., at 500 °C for 1 h under vacuum, CoO films were obtained. Cubic rocksalt-type CoO is known to exhibit Mott insulator property owing to its strongly correlated electron system.66 As shown in Fig. 4a, the [001]-oriented lamellar Co-LHS film was thermally transformed into a 200 nm-thick mesoporous film composed of a myriad of particles of 30 nm in diameter.

Fig. 4b (top) shows the out-of-plane XRD pattern of the resulting mesoporous film, which revealed the formation of CoO with a cubic rocksalt structure (ICDD no. 48-1719). No other phases were detected. A sharp intense peak due to CoO was observed at  $2\theta = 36.48^{\circ}$  accompanied by a weak peak at 77.53°, which can be assigned to 111 and 222 diffractions, respectively. Furthermore, a 220 diffraction peak was observed in the in-plane XRD pattern (Fig. 4b bottom), and the angle between the (111) and ( $1\bar{1}0$ ) planes is 90° in the cubic system, confirming the [111] crystal orientation of the resulting CoO MPF. The crystallite size of the CoO was estimated to be 23.6 nm

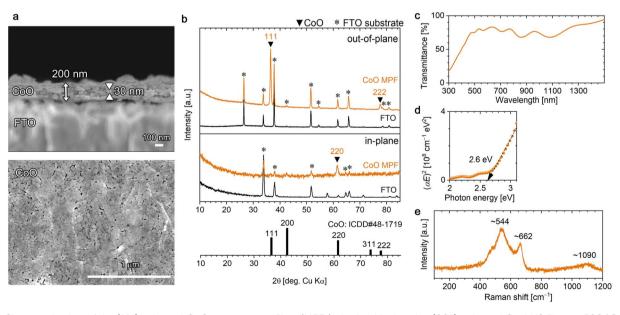


Fig. 4 Characterization of the [111]-oriented CoO mesoporous films (MPFs) obtained by heating [001]-oriented Co-LHS films at 500 °C for 1 h under vacuum: (a) cross-sectional (top) and plan-view (bottom) FESEM images, (b) out-of-plane (top) and in-plane (bottom) XRD patterns, (c) UV-vis-NIR transmittance spectrum, (d) Tauc plots and (e) Raman spectrum. ICDD data (no. 48-1719) for CoO with a cubic rocksalt structure is presented in (b).

in diameter using the Scherrer equation, which is consistent with the grain size observed in the FESEM images and suggests that each particle is single-crystal CoO. In the fine XPS measurements (Fig. S6a†), O 1s and Co  $2p_{3/2}$  peaks were observed at 529.8 and 780.4 eV, respectively, which are in agreement with the literature.  $^{67}$ 

The obtained [111]-oriented CoO MPFs exhibited a pale olive colour (Fig. S4b†) and 70–80% optical transmittance in the visible region (Fig. 4c). The bandgap energy was estimated from the direct-transition Tauc plots to be 2.6 eV, which is consistent with the literature value (Fig. 4d).  $^{32,67}$  In the ATR-FTIR spectrum (Fig. S6b†), no significant bands except for those of the substrate were detected, confirming the negligible presence of – OH or  $\rm H_2O$ . A broad peak due to Co–O vibrations should appear around 510 cm $^{-1}$ ,  $^{64}$  but this value is outside the measurement range used in this study.

The Raman spectrum of the obtained CoO MPF, which differed considerably from that of Co<sub>3</sub>O<sub>4</sub>, exhibited a broad peak at  $\sim$ 544 cm<sup>-1</sup> with a shoulder at  $\sim$ 662 cm<sup>-1</sup> (Fig. 4e). The rocksalt structure with a centrosymmetric lattice is generally a weak Raman scatter, where a first-order phonon scattering is forbidden due to the selection rules, whereas a two-phonon Raman scattering is allowed.<sup>68</sup> Rivas-Murias et al. reported similar Raman spectra with a broad peak at 530 cm<sup>-1</sup> and a weak shoulder at 680 cm<sup>-1</sup> for octahedrally faceted CoO nanocrystals with a size of ~60 nm.69 According to this, the observed broad peak at ∼544 cm<sup>-1</sup> can be assigned to cobalt or structural defects inducing one-phonon longitudinal optical Raman scattering, and the shoulder peak is attributable to Co<sub>3</sub>O<sub>4</sub> slightly generated upon laser irradiation. Thereby, the weak broad peak observed at ~1090 cm<sup>-1</sup> is assignable to second-order two-phonon Raman scattering.64 The appearance of inherently forbidden Raman scattering with more intensity than the allowed one has been previously reported for rocksalttype NiO nanocrystals (~36 nm diameter).47

# Plausible mechanism for the transformation from [001]- $\alpha$ -Co-LHS to [111]-Co<sub>3</sub>O<sub>4</sub> and [111]-CoO

The above results demonstrate that [111]-oriented MPFs of Co<sub>3</sub>O<sub>4</sub> and CoO can be successfully obtained from [001]-oriented α-Co-LHS continuous films. Up to now, topotactic-like formation of oriented cobalt oxide on substrates has been limited to using microcrystal hydroxides as precursors.32,45 To the best of our knowledge, this is the first example of a centimetre-size continuous film with indistinct grain boundaries undergoing oriented transformation to yield cobalt oxide films. Nevertheless, the observed orientation relationship, that is,  $\alpha$ -Co-LHS[001]//  $Co_3O_4[111]$  and  $\alpha$ -Co-LHS[001]//CoO[111], must be explained from a microscopic view point. In fact, even if the starting hydroxide is single-crystal Mg(OH)<sub>2</sub> with a simple brucite structure, aggregates of uniform MgO nanoparticles with a size of several nanometers are initially produced, suggesting that the TPT process occurs on a nanodomain unit.70 Thus, in the present case, the TPT process occurring in the numerous nanodomains of the [001]-stacking α-Co-LHS layers likely produced a myriad of [111]-oriented Co<sub>x</sub>O<sub>y</sub> nanocrystals, resulting in centimetre-scale

[111]-oriented mesoporous oxide films as a whole. Here, the conversion processes are discussed in terms of the nanoregion structure, *i.e.*, the atomic framework, of the starting hydroxides and product oxides.

The structure of the α-Co-LHS films obtained in this study consists of 2D O<sub>h</sub>-T<sub>d</sub> Co(OH)<sub>r</sub> sheets and the interlayer NO<sub>3</sub> and H<sub>2</sub>O (Fig. 5a). The O<sub>h</sub>/T<sub>d</sub> ratio depends on the metal and anion species,<sup>71</sup> and the proposed structure was constructed on the basis of previously reported Zn<sub>5</sub>(OH)<sub>8</sub>Cl<sub>2</sub>·H<sub>2</sub>O with definite crystallographic information. The cross-sectional structure of the (001) plane is shown in Fig. 5d, where the 2D  $O_h$ - $T_d$   $Co(OH)_x$ sheets are stacked in the [001] direction. When the interlayer NO<sub>3</sub> and H<sub>2</sub>O molecules disappear upon heating, the 2D O<sub>h</sub>-T<sub>d</sub> Co(OH)x sheets approach each other to form an interlocked structure as shown in Fig. 5e, whose components are indicated by A-C. The corresponding top view images, i.e., the atomic framework of the (001) planes of A, B and C layers, are extracted in Fig. 5h. In A(001), there are regular vacancies in the 2D planar layer composed of edge-sharing O<sub>h</sub>-Co<sup>2+</sup> layers. **B**(001) is composed of isolated T<sub>d</sub>-Co<sup>2+</sup> arranged in a three-fold symmetry, and C(001) has a structure in which the vacancies in **A** are filled with  $T_d$ -Co<sup>2+</sup>.

The crystal structures of Co<sub>3</sub>O<sub>4</sub> and CoO are shown in Fig. 5b and c, respectively. Spinel-type Co<sub>3</sub>O<sub>4</sub> is composed of T<sub>d</sub>-Co<sup>2+</sup> and O<sub>h</sub>-Co<sup>3+</sup> and can be formally represented as [Co<sup>2+</sup>]<sub>Td</sub>[2-Co<sup>3+</sup><sub>Oh</sub>O<sub>4</sub>. Fig. 5f displays a crystal structure of the Co<sub>3</sub>O<sub>4</sub>(011) plane with the [111] direction pointing upward and two layers denoted by D and E alternately stacked. The corresponding (111) planes of these D and E layers are depicted in Fig. 5i. Interestingly, the atomic framework of D(111) is identical to that of A(001), and the slightly smaller dimension of D(111) is likely due to the difference in ionic radii of Co<sup>2+</sup> (0.65 Å) and Co<sup>3+</sup> (0.55 Å) for **A** and **D**, respectively.<sup>72</sup> Thus, in the transformation, the  $\alpha$ -Co-LHS A layer is most likely the main component forming the Co<sub>3</sub>O<sub>4</sub> D layer. Meanwhile, Co<sub>3</sub>O<sub>4</sub> E(111) consists mainly of T<sub>d</sub>-Co<sup>2+</sup> with a three-fold symmetry and could be formed by a slight rearrangement of the α-Co-LHS B layer. Indeed, magnetic moment studies suggested that T<sub>d</sub>-Co<sup>2+</sup> in α-Co-LHS is maintained during the conversion to Co<sub>3</sub>O<sub>4</sub>.26

The other cobalt oxide, rocksalt-type CoO, has a simple atomic framework consisting only of  $O_h\text{-}\mathrm{Co}^{2^+}$  (Fig. 5c). As shown in Fig. 5g, the (011) plane with the [111] direction pointing upward is a stack of  $O_h\text{-}\mathrm{Co}^{2^+}$  layers denoted as F. The F(111) structure shown in Fig. 5j has an atomic framework similar to that of A(001) but without vacancies. Thus, while the formation of the F(111) layer can be explained by considering a C(001) layer with vacancies filled with  $T_d\text{-}\mathrm{Co}^{2^+}$ , an excess of cobalt atoms might be present.

A comparison of the atomic frameworks reveals that the [001]-direction of  $\alpha$ -Co-LHS and the [111]-direction of  $\mathrm{Co}_x\mathrm{O}_y$  have an apparent common structure with alternating layers of cobalt and oxygen atoms, as well as highly similar crystal plane structures, *i.e.*, **A–F**. This 3D similarity in the atomic frameworks may provide a topotactic-like transformation from the [001]-oriented  $\alpha$ -Co-LHS film to [111]-oriented  $\mathrm{Co}_3\mathrm{O}_4$  and  $\mathrm{CoO}$  films with minimal atomic rearrangements. In other words, the

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а **b** Co<sub>3</sub>O<sub>4</sub>: [Co<sup>2+</sup>]<sub>Td</sub> [2Co<sup>3+</sup>]<sub>Oh</sub>O<sub>4</sub> α-Co-LHS CoO Co (Oh) 8.3-8.9 Cubic (Spinel) Cubic (Rock salt) a, b, c = 4.26 Åa, b, c = 8.08 Å $\alpha$ ,  $\beta$ ,  $\gamma$  = 90.0 deg.  $\alpha$ ,  $\beta$ ,  $\gamma$  = 90.0 deg. [001] d [1111]Crosssectional view F (111) A (001) B (001) C (001) D (111) E (111) Top view

Fig. 5 Crystal model of (a)  $\alpha$ -Co-LHS (drawn on the basis of Zn<sub>5</sub>(OH)<sub>8</sub>Cl<sub>2</sub>·H<sub>2</sub>O with modifications), (b) Co<sub>3</sub>O<sub>4</sub> and (c) CoO. (d-g) Cross-sectional view of crystal models parallel in the (d, e)  $\alpha$ -Co-LHS[001], (f) Co<sub>3</sub>O<sub>4</sub>[111] and (g) CoO[111] directions. (h—j) Top view of crystal models for the (h) α-Co-LHS (001), (i) Co<sub>3</sub>O<sub>4</sub>(111) and (j) CoO(111) planes corresponding to the A-F components indicated in (e-g). The length of the atomic framework of A(001) is calculated on the basis of  $\alpha$ -Co-LHS containing Cl and H<sub>2</sub>O in the interlayer (lattice constant a=3.14 Å), <sup>55</sup> which has the same space group as that of Zn<sub>5</sub>(OH)<sub>8</sub>Cl<sub>2</sub>·H<sub>2</sub>O.

experimental results suggest that even low-crystalline  $\alpha$ -type LHSs have a regular structure that satisfies topotactic transformation in their nanodomains.

# Experimental

#### Materials

Cobalt(II) nitrate hexahydrate (Co(NO<sub>3</sub>)<sub>2</sub>·6H<sub>2</sub>O<sub>4</sub>  $\geq$ 98.0%) and platinum plate (99.95%) were purchased from Nacalai Tesque Inc. and Nilaco Co. and used as received. The aqueous solution for electrodeposition was prepared using deionized water (>10 MΩ cm) purified using a Millipore Elix Advanced5 system. FTOcoated glass ( $\sim$ 10  $\Omega$ /sq, Asahi Glass) was used as a substrate.

#### Synthesis of [001]-oriented α-Co-LHS films

Before electrodeposition, FTO substrates were treated with a UV-ozone cleaner for 10 min and then rinsed with deionized water. α-Co-LHS films were electrochemically deposited using a potentiostat/galvanostat (Hokuto Denko HABF5001) and a conventional two-electrode glass vessel consisting of the FTO substrate (1.5  $\times$  4.0 cm in size with a deposition area of 3.75 cm<sup>2</sup>) as the working electrode and the platinum plate as the counter electrode. Galvanostatic electrolysis was performed in an aqueous solution containing 10 mM Co(NO<sub>3</sub>)<sub>2</sub> using a cathodic constant current of  $-1.0 \text{ mA cm}^{-2}$  for 3.3 min (total quantity of electricity  $-0.2 \text{ C cm}^{-2}$ ) at room temperature. After deposition, the deposits were gently rinsed with deionized water and dried at room temperature under vacuum.

#### Synthesis of [111]-oriented Co<sub>3</sub>O<sub>4</sub> and CoO MPFs

[111]-Oriented Co<sub>3</sub>O<sub>4</sub> MPFs were prepared by heating the electrodeposited [001]-oriented α-Co-LHS films in air at 550 °C for 1 h at a heating rate of 10 °C min<sup>-1</sup> using an electric muffle furnace. [111]-Oriented CoO MPFs were prepared by heating the [001]-oriented α-Co-LHS films under vacuum (approximately 1  $\times$  10<sup>-3</sup> Pa) at 500 °C for 1 h at a heating rate of 5 °C min<sup>-1</sup> using a quartz tube furnace with an oil diffusion pump.

#### Characterization

Cross-sectional and surface FESEM images of films deposited on the FTO substrates were obtained using a JEOL JSM-6700F microscope with an acceleration voltage of 5.0 kV. Out-ofplane  $(\theta-2\theta)$  and in-plane  $(\omega - 2\theta\chi/\varphi)$  XRD patterns were obtained using a Rigaku SmartLab diffractometer with Cu Kα radiation operated at 6 kW. XPS spectra were recorded with a Kratos AXIS-Ultra DLD spectrometer using monochromated Al Kα radiation operated at 60 W. UV-vis-NIR transmittance spectra were recorded on a Shimadzu UV-3150 spectrophotometer using an integrating sphere with respect to the FTO substrate. ATR-FTIR spectra were recorded using a Thermo Nicolet 4700 spectrophotometer with a diamond reflection crystal unit (DuraSample IRII). Raman spectra were recorded using a microscopic laser Raman spectrometer (Horiba Lab-RAM HR Evolution) with a laser wavelength of 532 nm.

## Conclusions

In summary, we have demonstrated the successful formation of [111]-oriented mesoporous films of Co<sub>3</sub>O<sub>4</sub> and CoO as a result of the TPT of [001]-oriented stacking films of  $\alpha$ -Co-LHS. [001]- $\alpha$ -Co-LHS having a unique stacking continuous film structure was prepared on FTO substrates using a simple electrodeposition method from Co(NO<sub>3</sub>)<sub>2</sub> aqueous solution at room temperature. A detailed characterization revealed that [001]-α-Co-LHS with an interlayer distance of 8.3-8.9 Å contained NO<sub>3</sub> and H<sub>2</sub>O in the interlayer, and its 2D Co(OH)<sub>x</sub> sheets consisted of edge-shared O<sub>h</sub>-Co<sup>2+</sup> sheets partially sandwiched with T<sub>d</sub>-Co<sup>2+</sup>. [111]oriented Co<sub>3</sub>O<sub>4</sub> and CoO films were obtained upon calcination of the [001]- $\alpha$ -Co-LHS films at different conditions, *i.e.*, in air at 550 °C and under vacuum at 500 °C, respectively. The resulting Co<sub>3</sub>O<sub>4</sub> and CoO have a mesoporous structure consisting of an aggregation of numerous [111]-oriented nanocrystals with a diameter of  $\sim$ 70 and  $\sim$ 30 nm, respectively. The formation of the [111]-oriented Co<sub>3</sub>O<sub>4</sub> and CoO films from the [001]-α-Co-LHS continuous films suggests that TPT proceeded on a centimetre-scale. A comparison between the atomic frameworks of α-Co-LHS and the cobalt oxides, Co<sub>3</sub>O<sub>4</sub> and CoO, revealed similarities in the atomic arrangement of the  $\alpha$ -Co-LHS(001) and cobalt oxide(111) planes. It can be concluded that the assembly of regular transformations in the nanoregion results in the centimetre-scale TPT.

## Author contributions

This work was designed and directed by T. S. with the support of A. O. T. S. and N. K. performed the experiments and analysed these data. The manuscript was prepared by T. S. supported by discussions with all the other authors.

#### Conflicts of interest

There are no conflicts to declare.

# Acknowledgements

A part of this work was supported by Grants-in-Aid for Scientific Research (C) (JSPS KAKENHI no. 22K05281).

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